

Adaptable wire-length distribution with tunable occupation probability

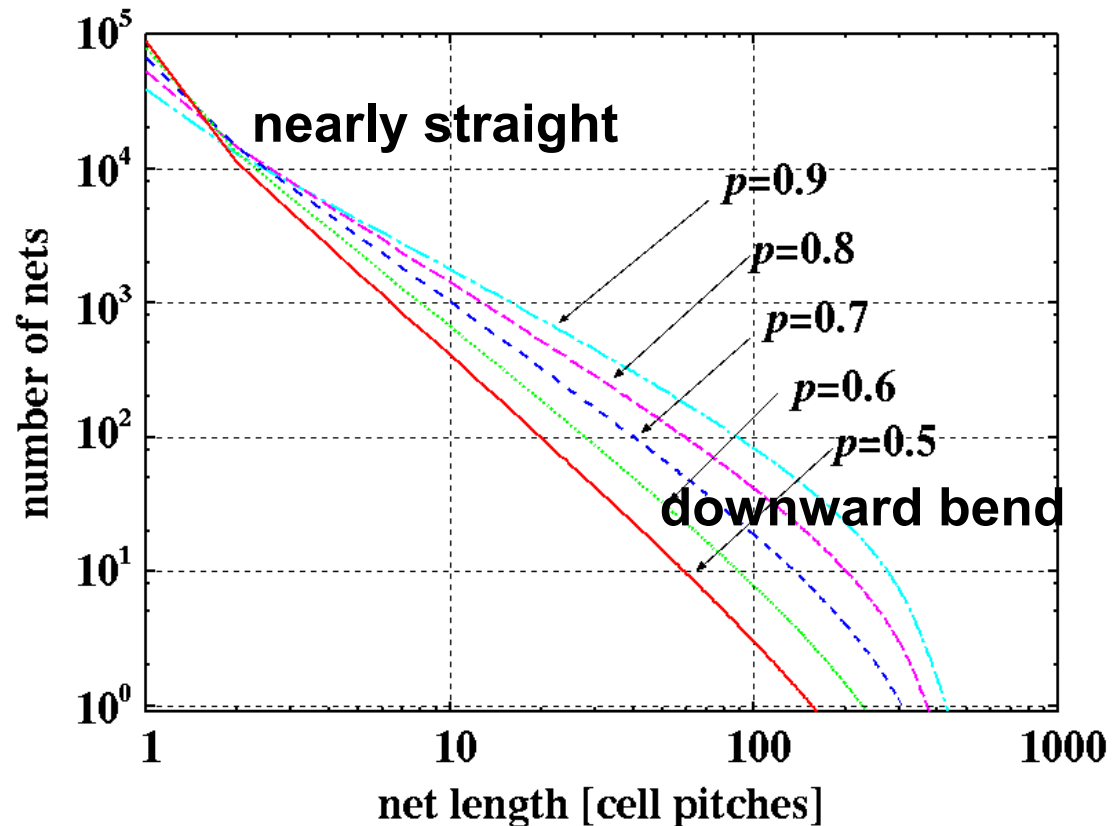
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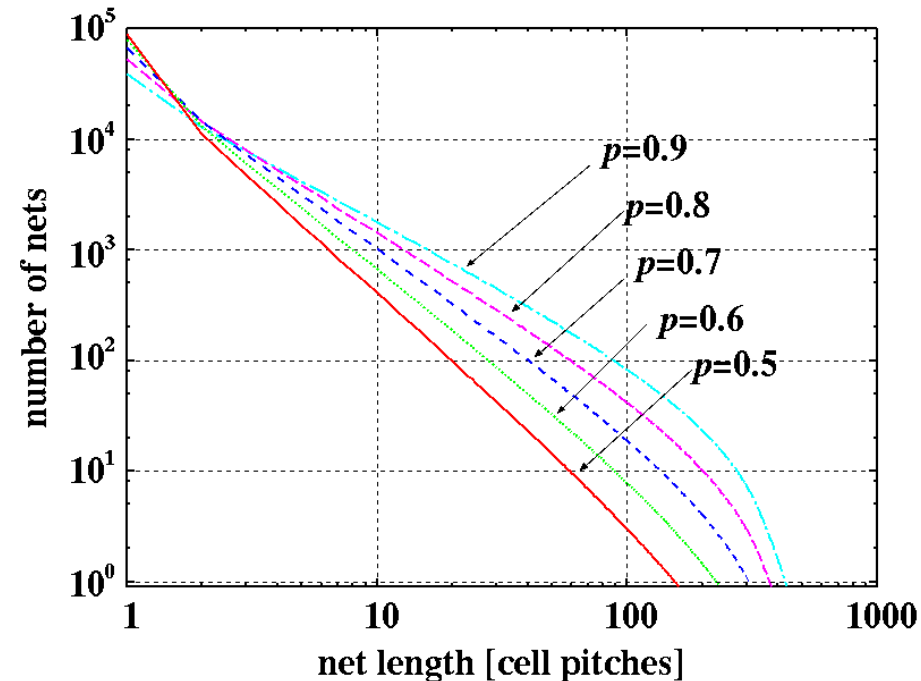
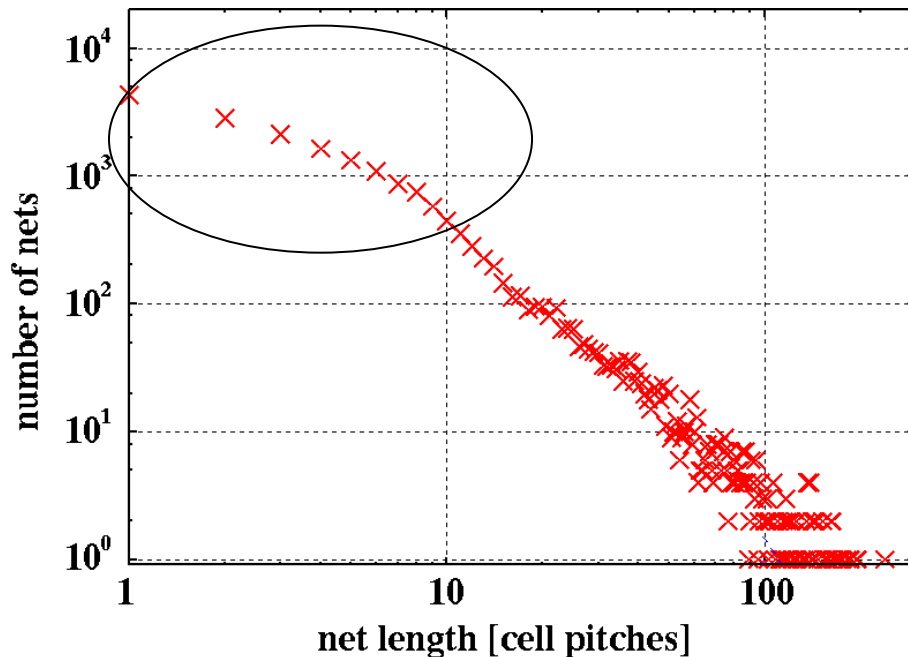
- Motivation---Why do we care?
- Flat (non-hierarchical) wire-length distribution models
- Tunable occupation probability
- Comparison with real data
- Conclusions

- Typical model wire-length distribution exhibits a nearly straight line (plus a downward bend) on log-log scale

- Flat model from Ref [1]
- p is Rent exponent
- Rent coefficient doesn't affect the shape of the distribution



- Real wire-length distribution often doesn't show as many short wires
 - Predicted average wire length could be too short



- Real data like above cannot be expressed by the model shown

- To develop a wire-length distribution model that can well reproduce real data
 - We want to be sure that we are not far off at the starting point (before starting predicting anything)
- The model must be simple
 - It must be many orders of magnitude faster than placement & routing
 - It must be easy to use

- Wire-length distribution $w(\ell)$: Cell pairs are actually connected by wires according to $q(\ell)$

$$w(\ell) = Kq(\ell)D(\ell)$$

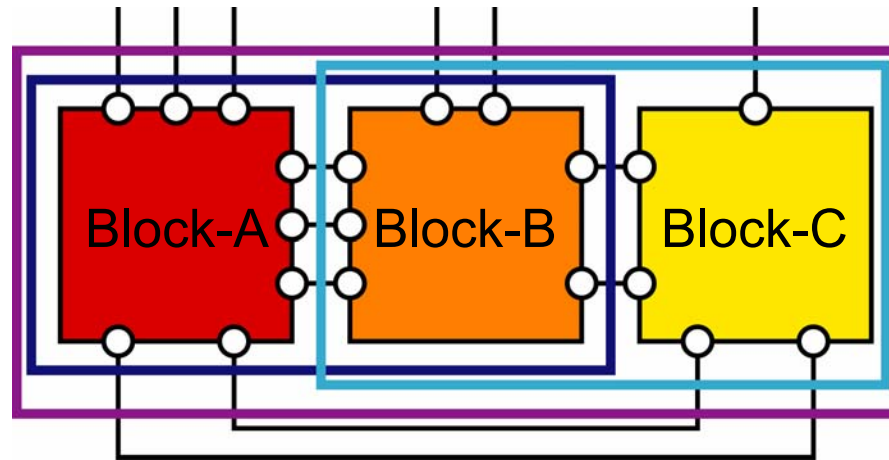
$$K = \frac{W_{\text{total}}}{\sum_{\ell=1}^{\ell_{\text{max}}} q(\ell)D(\ell)}$$

- Electron density $n(\varepsilon)$: Orbitals are filled with electrons according to Fermi distribution $f(\varepsilon)$

$$n(\varepsilon)d\varepsilon = f(\varepsilon)D(\varepsilon)d\varepsilon$$

$D(\varepsilon)$: Density of states

$f(\varepsilon)$: Fermi function



$$T_{A \leftrightarrow C} = T_{AB} + T_{BC} - T_B - T_{ABC}$$

4 9 8 7 6

- If the number of cells in each block is known

$$T_{A \leftrightarrow C} = R(N_A + N_B) + R(N_B + N_C) \\ - R(N_B) - R(N_A + N_B + N_C)$$

$$R(N) = kN^p \quad (\text{Rent's rule})$$

- If blocks A, B, and C are arranged as shown,

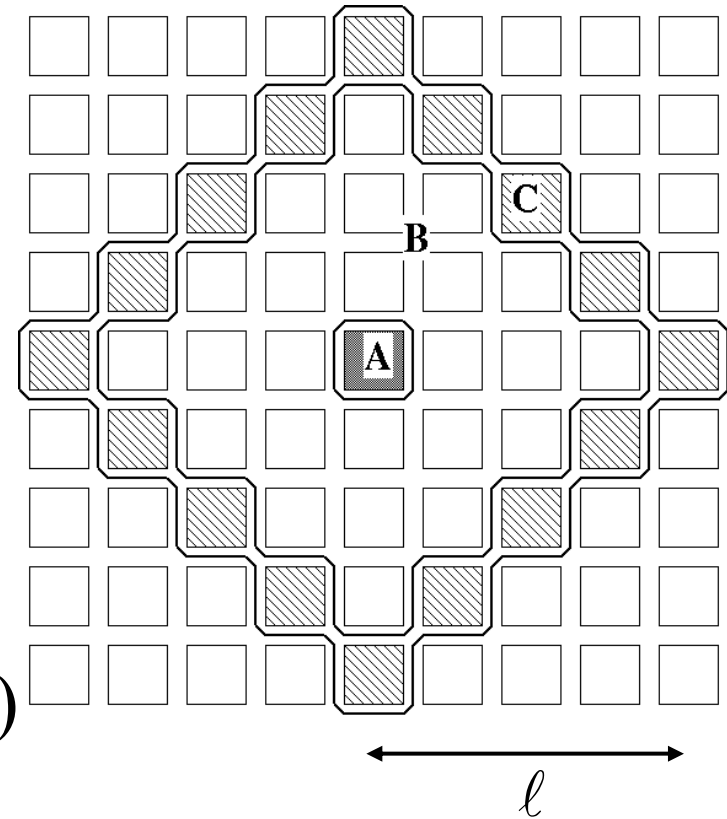
$$N_A = 1, N_B = 2\ell(\ell - 1), N_C = 4\ell$$

$$T_{A \leftrightarrow B}(\ell) = R(N_A) + R(N_B) - R(N_A + N_B)$$

$$T_{A \leftrightarrow C}(\ell) = R(N_A + N_B) + R(N_B + N_C) - R(N_B) - R(N_A + N_B + N_C)$$

- Recurrence formula

$$T_{A \leftrightarrow B}(\ell + 1) = T_{A \leftrightarrow B}(\ell) + T_{A \leftrightarrow C}(\ell)$$



- From the recurrence formula and Rent's rule follows

$$\lim_{\ell \rightarrow \infty} T_{A \leftrightarrow B}(\ell) = \lim_{\ell \rightarrow \infty} \sum_{r=1}^{\ell-1} T_{A \leftrightarrow C}(r) = k$$

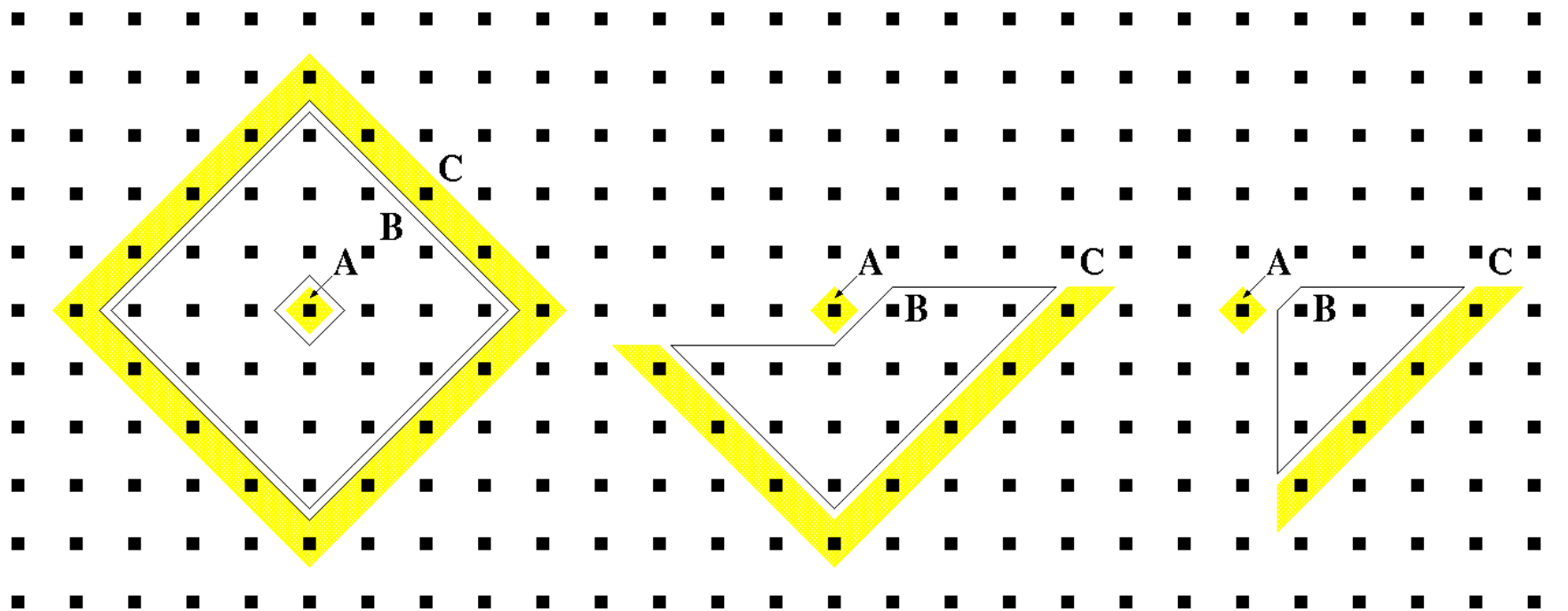
- A probability function can be introduced by

$$\text{prob}_{A \leftrightarrow C}(\ell) = \frac{1}{k} T_{A \leftrightarrow C}(\ell)$$

- Occupation probability function $q(\ell)$ is defined by

$$q(\ell) = \frac{1}{2\ell} \text{prob}_{A \leftrightarrow C}(\ell)$$

- All the following are valid configurations in defining $q(\ell)$



full Manhattan circle

$$N_A = 1$$

$$N_B = 2\ell(\ell - 1)$$

$$N_C = 4\ell$$

half Manhattan circle

$$N_A = 1$$

$$N_B = \ell(\ell - 1)$$

$$N_C = 2\ell$$

quarter Manhattan circle

$$N_A = 1$$

$$N_B = \ell(\ell - 1) / 2$$

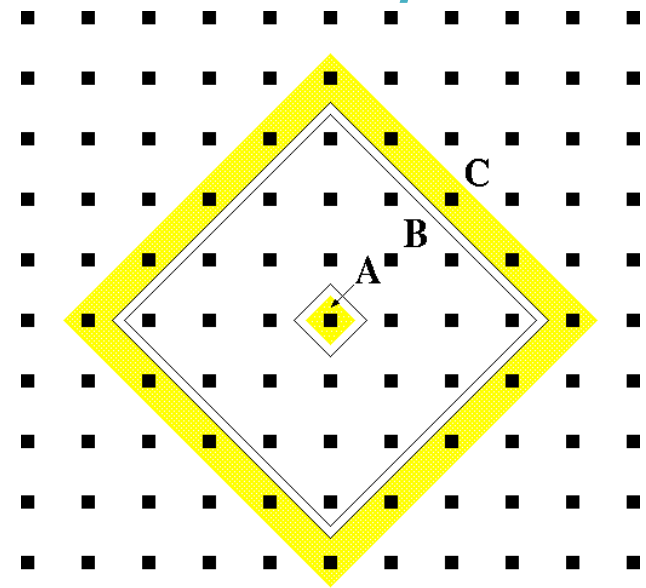
$$N_C = \ell$$

- Ref [1] uses

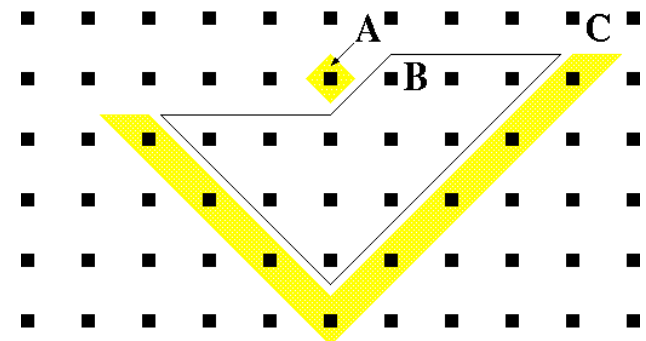
$N_A = 1, N_B = 2\ell(\ell - 1), N_C = 4\ell$
corresponding to full
Manhattan circle configuration

- Ref [2] uses

$N_A = 1, N_B = \ell(\ell - 1), N_C = 2\ell$
corresponding to half
Manhattan circle configuration



full Manhattan circle



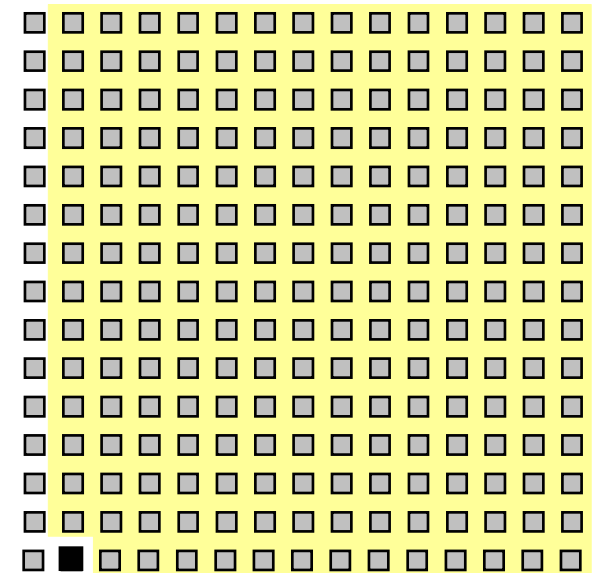
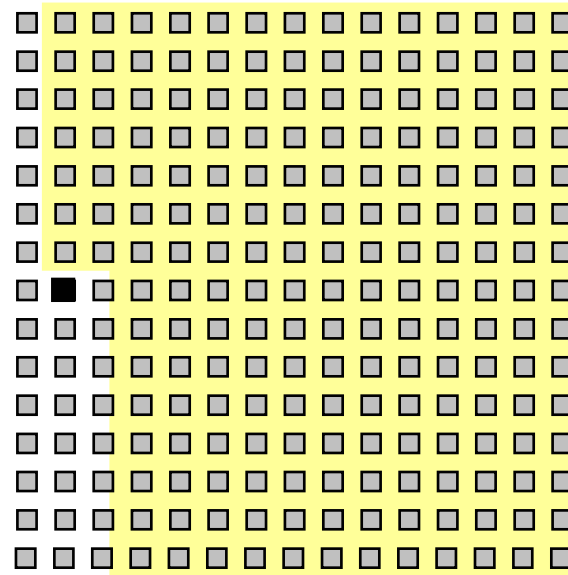
half Manhattan circle

[1] Christie & Stroobandt, IEEE Trans. VLSI Syst., vol.8, no.6, pp.639-648, 2000.

[2] Davis, De, Meindl, IEEE Trans. Electron Devices, vol.45, no.3, pp.580-589, 1998.

Which configuration to use?

- If a cell under consideration is near an edge, half Manhattan should be appropriate
- Likewise, if a cell is near a corner, quarter Manhattan circle should be used
- What is the best configuration on average?



- Cell numbers for a generalized partial Manhattan circle configuration

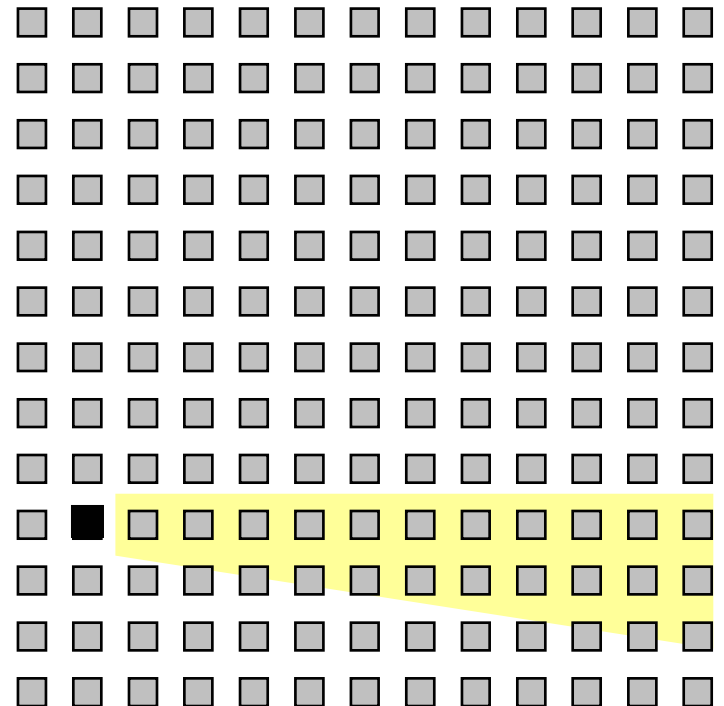
$$N_A = 1, \quad N_B = 2\zeta^{\ell}(\ell - 1), \quad N_C = 4\zeta^{\ell}$$

$$(0 < \zeta \leq 1)$$

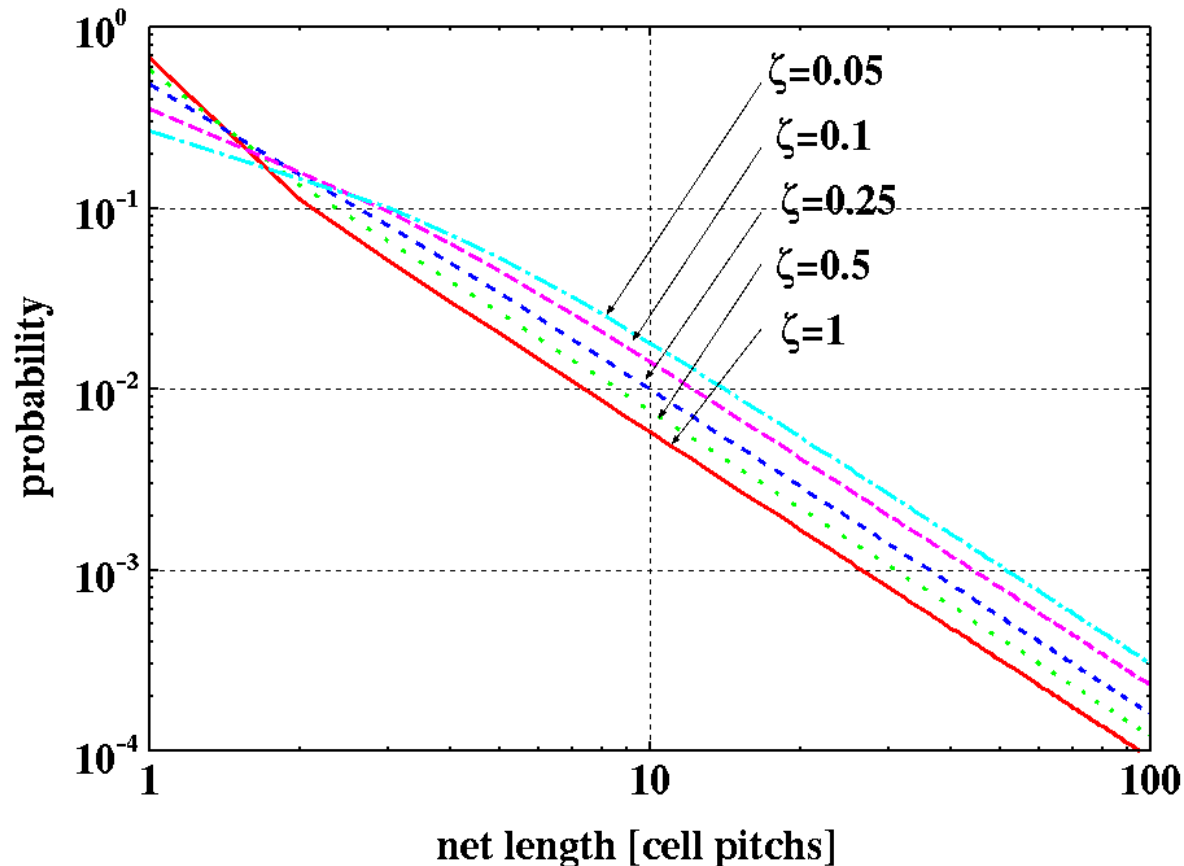
$\zeta = 1$: Full Manhattan circle

$\zeta = 0.5$: Half Manhattan circle

$\zeta = 0.25$: Quarter Manhattan circle



- $\text{prob}_{A \leftrightarrow C}(\ell)$ shows smaller ζ has the desired effect of reducing the numbers of short wires



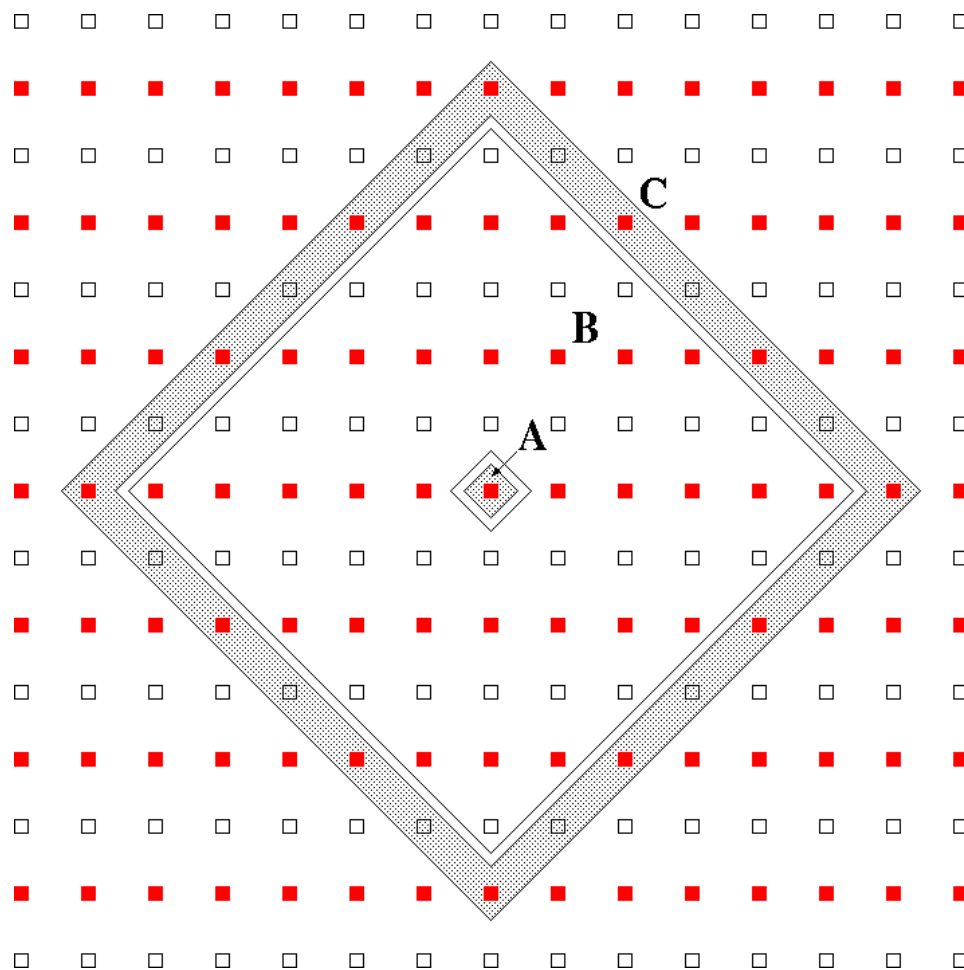
- Full Manhattan circle on a half occupied cell rows gives

$$N_A = 1$$

$$N_B = \ell(\ell - 1)$$

$$N_C = 2\ell$$

corresponding to
 $\zeta = 0.5$



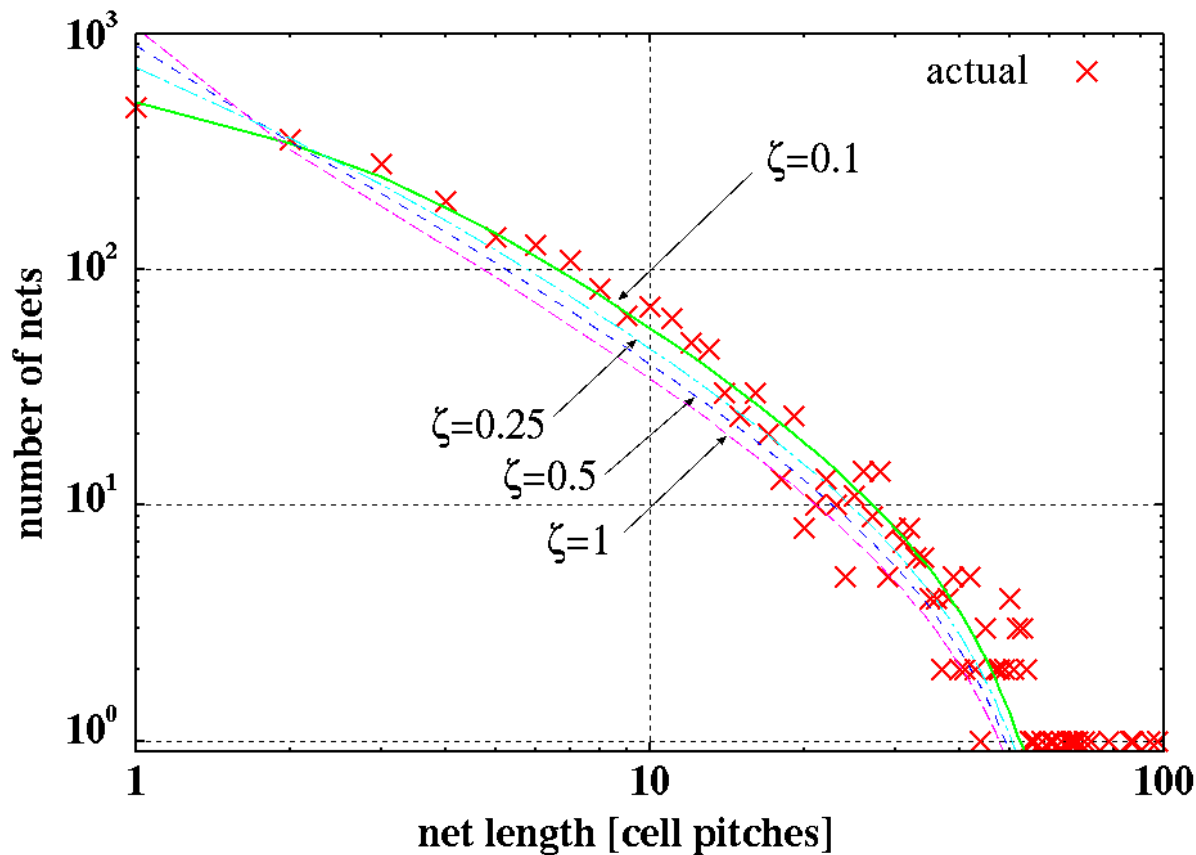
$$w(\ell) = Kq(\ell)D(\ell)$$

$$K = \frac{W_{\text{total}}}{\sum_{\ell=1}^{\ell_{\text{max}}} q(\ell)D(\ell)}$$

$$q(\ell) = \frac{1}{2\ell} \{ [1 + 2\zeta\ell(\ell - 1)]^p + [2\zeta\ell(\ell + 1)]^p \\ - [2\zeta\ell(\ell - 1)]^p - [1 + 2\zeta\ell(\ell + 1)]^p \}$$

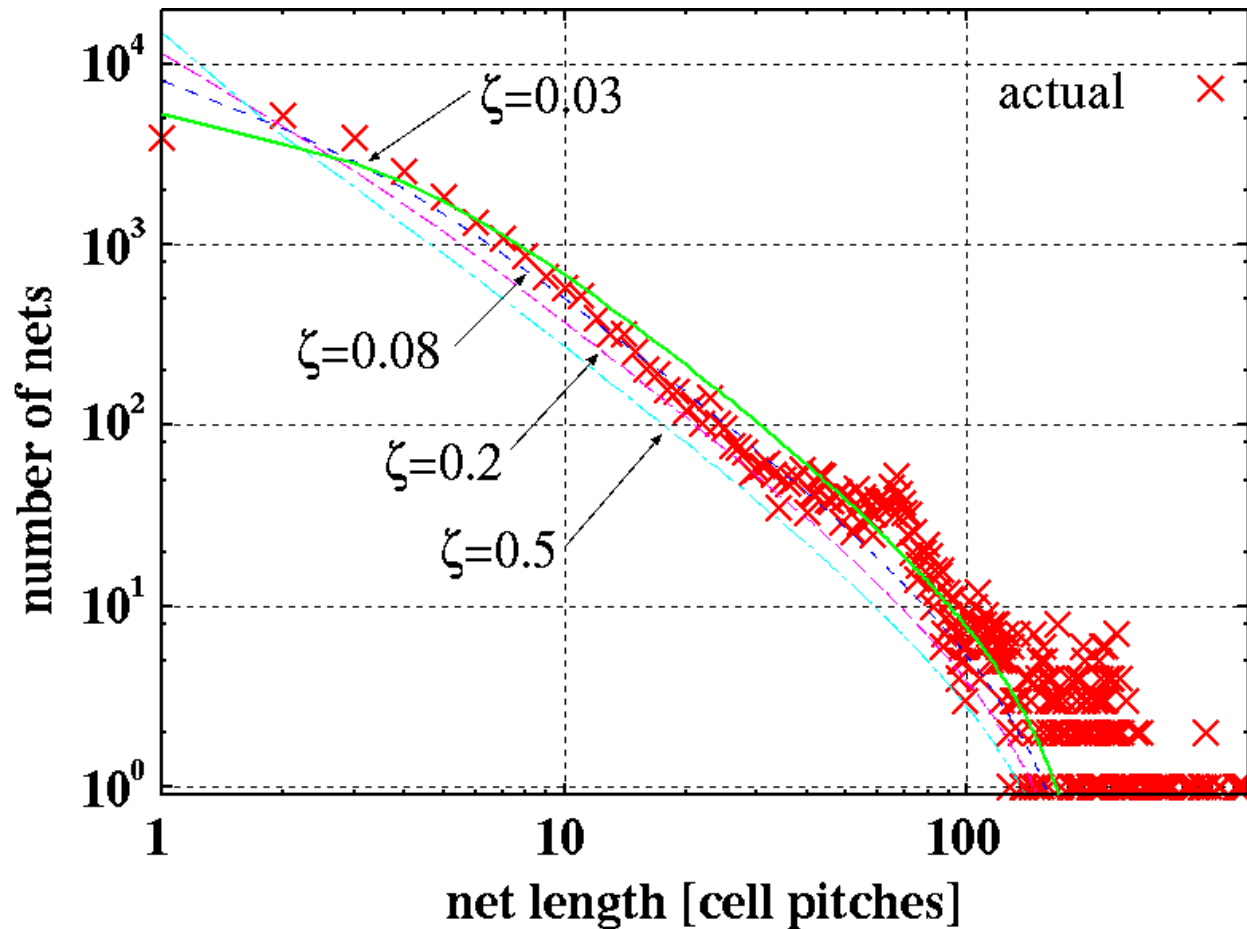
$$D(\ell) = \begin{cases} \frac{\ell(6L^2 - 6\ell L + \ell^2 - 1)}{3} & (1 \leq \ell < L) \\ \frac{(2L - \ell + 1)(2L - \ell)(2L - \ell - 1)}{3} & (L \leq \ell \leq 2L - 2) \\ 0 & \text{otherwise} \end{cases}$$

- 180nm CMOS, 2283 cells

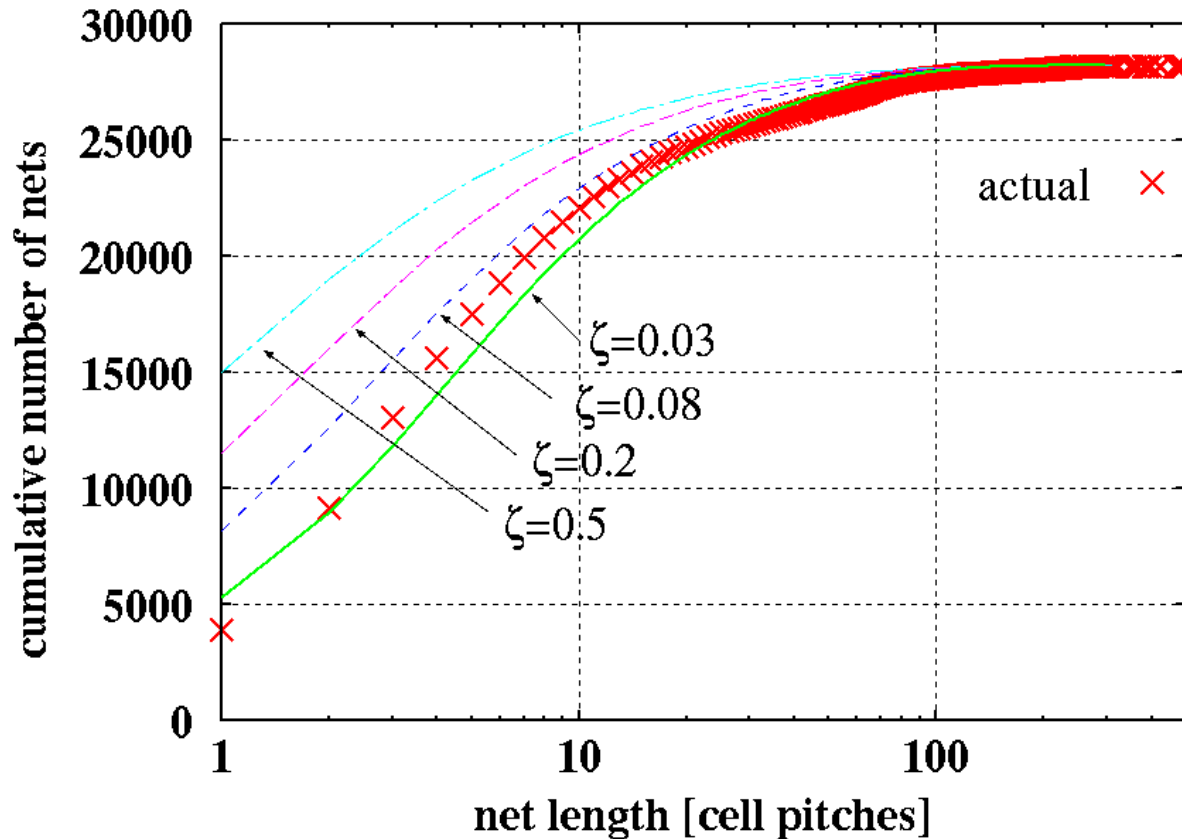


Condition	Avg. length
Actual	8.0
$\zeta = 0.1$	7.4
$\zeta = 0.25$	6.2
$\zeta = 0.5$	5.6
$\zeta = 1$	5.0

- 180nm CMOS, 24868 cells

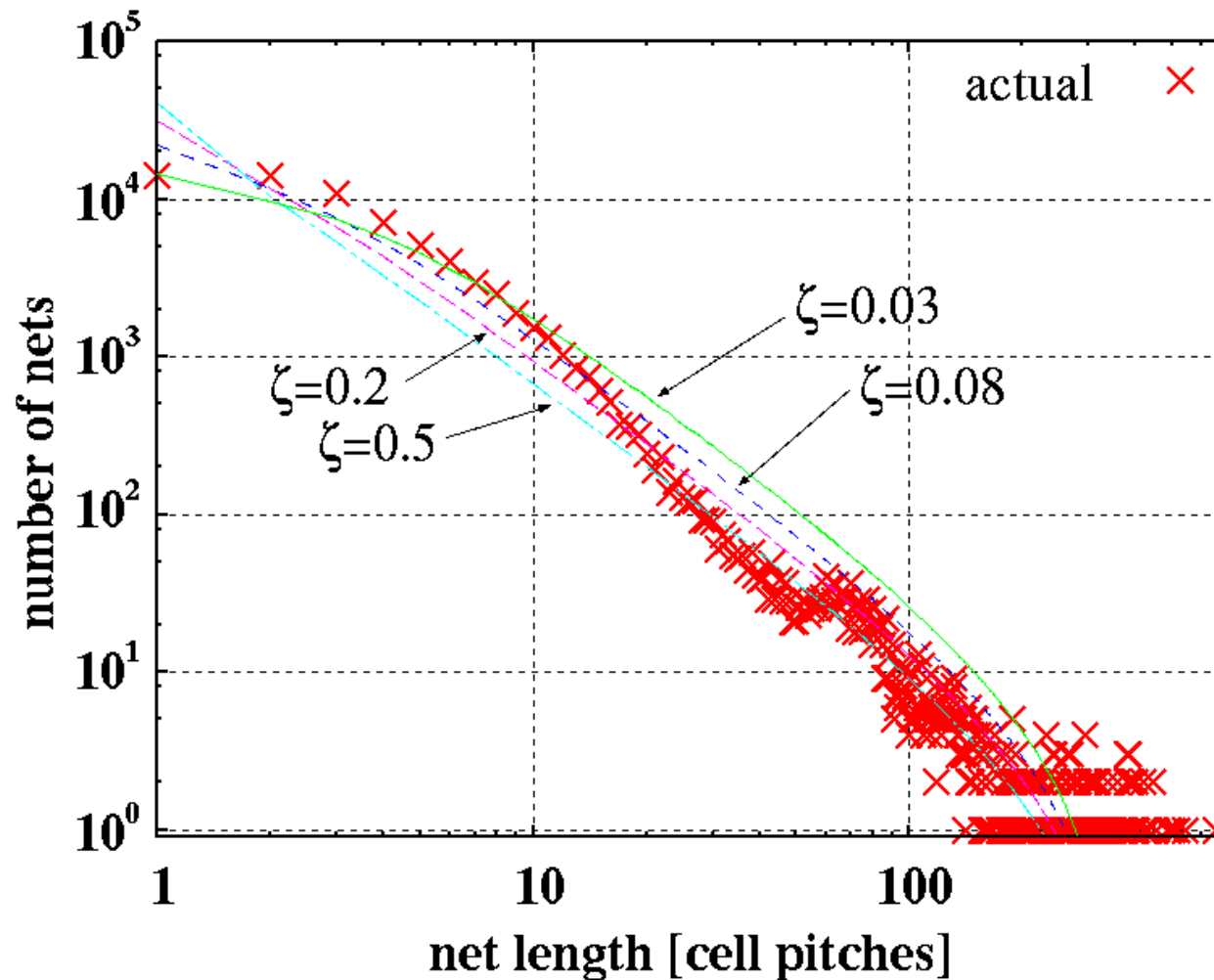


● 180nm CMOS, 24868 cells

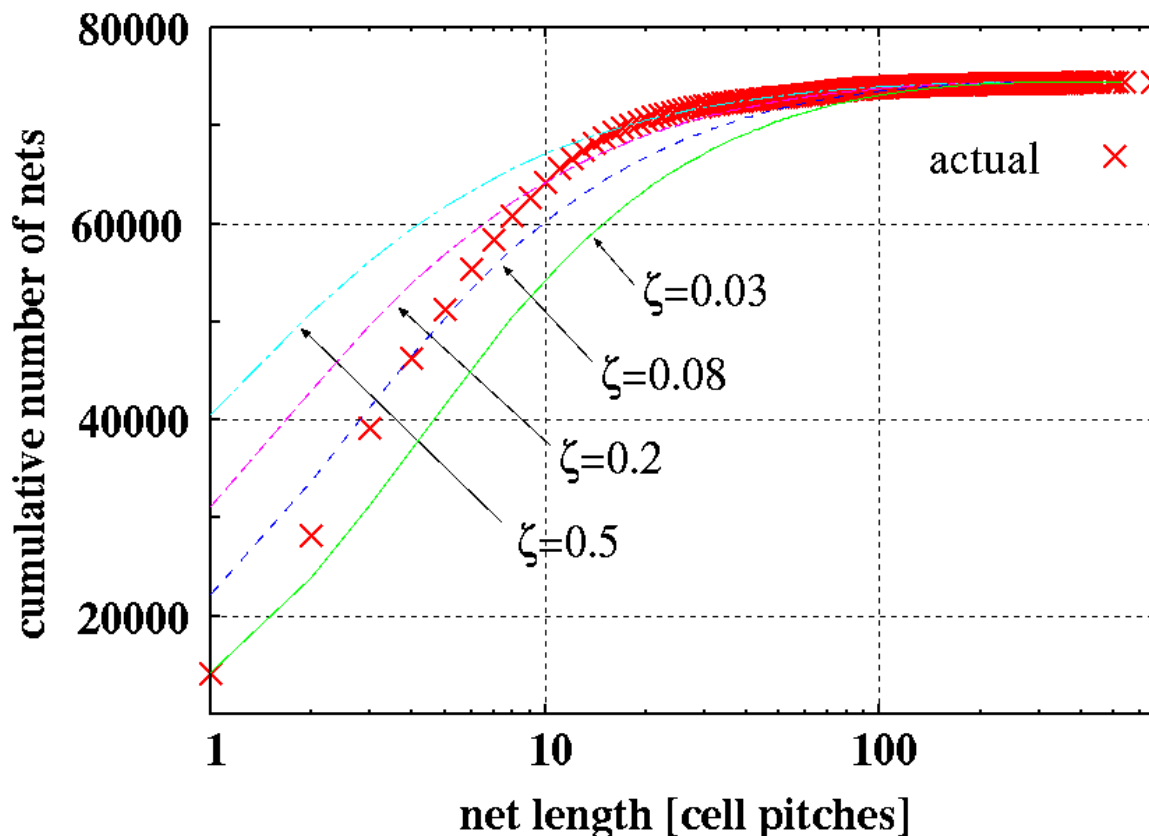


Condition	Avg. length
Actual	11.9
$\zeta = 0.03$	10.9
$\zeta = 0.08$	8.2
$\zeta = 0.2$	6.4
$\zeta = 0.5$	5.0

- 130nm CMOS, 70370 cells

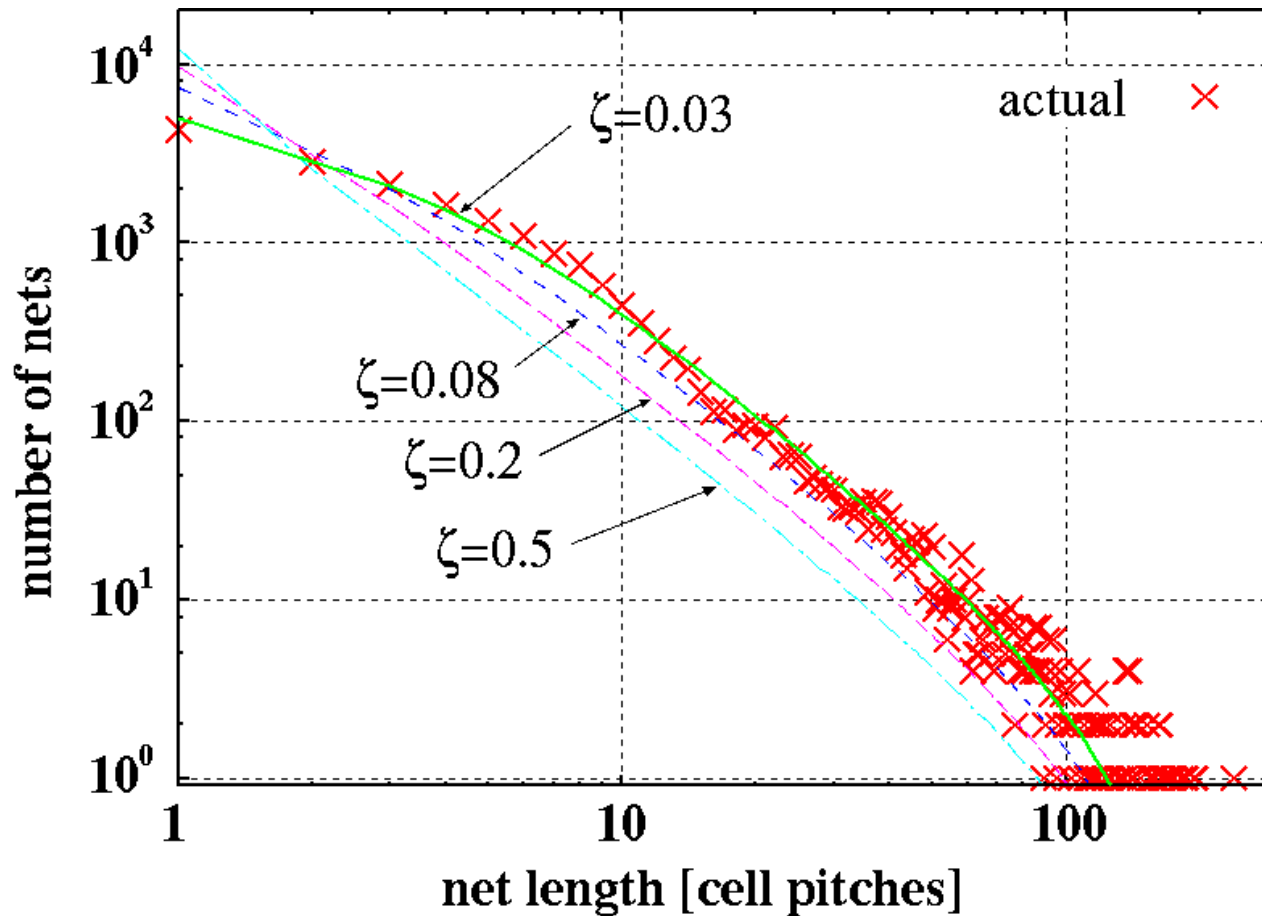


- 130nm CMOS, 70370 cells

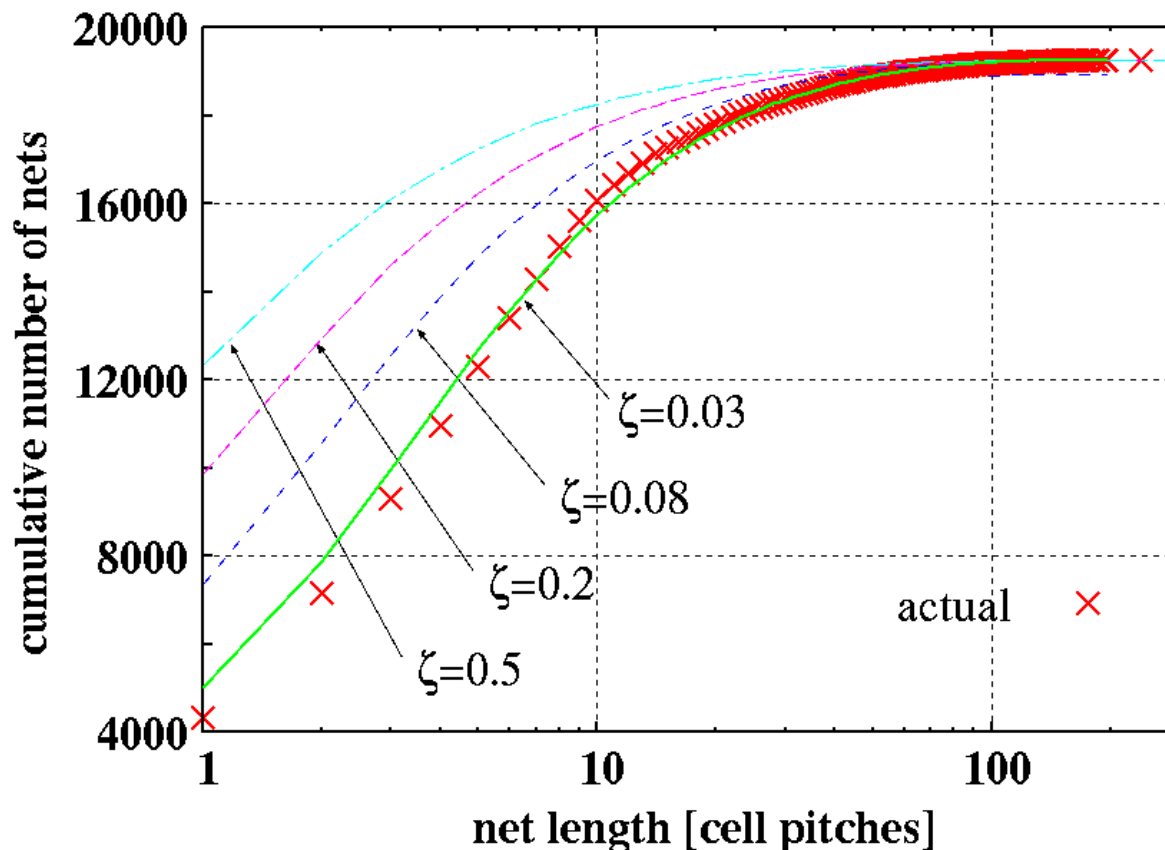


Condition	Avg. length
Actual	7.4
$\zeta = 0.03$	12.6
$\zeta = 0.08$	9.4
$\zeta = 0.2$	7.2
$\zeta = 0.5$	5.5

- 90nm CMOS, 19321 cells



● 90nm CMOS, 19321 cells



Condition	Avg. length
Actual	7.3
$\zeta = 0.03$	7.6
$\zeta = 0.08$	5.5
$\zeta = 0.2$	4.1
$\zeta = 0.5$	3.1

- A simple occupation probability function $q(\ell)$ with an extra degree of freedom that expresses non-idealities is proposed
- The proposed wire-length distribution model better reproduces experimental data especially in the short-wire-length region
- Effort should be made to strengthen the foundations of the model so that the parameter ζ can be determined a priori

Thank you.

The logo features the text 'TOKYO TECH' in a bold, blue, sans-serif font. A thick blue diagonal line crosses the text from the bottom left to the top right. Two horizontal blue lines extend from the left and right sides of the text, intersecting the diagonal line.

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$$N_A = 1, N_B = 2\ell(\ell - 1), N_C = 4\ell$$

$$N_A = 1, N_B = \ell(\ell - 1), N_C = 2\ell$$

$$N_A = 1, N_B = \frac{\ell(\ell - 1)}{2}, N_C = \ell$$

$$\lim_{\ell \rightarrow \infty} \sum_{r=1}^{\ell-1} \text{prob}_{A \leftrightarrow C}(r) = 1$$

[1] Christie & Stroobandt, "The interpretation and application of Rent's rule," IEEE Trans. VLSI Syst., vol.8, no.6, pp.639-648, 2000.

[2] Davis, De, Meindl, "A stochastic wire-length distribution for gigascale integration (GSI)---Part I: Derivation and validation," IEEE Trans. Electron Devices, vol.45, no.3, pp.580-589, 1998.

- If blocks A, B, and C are arranged as shown,

$$N_A = 1, N_B = 2\ell(\ell - 1), N_C = 4\ell$$

- From the recurrence formula

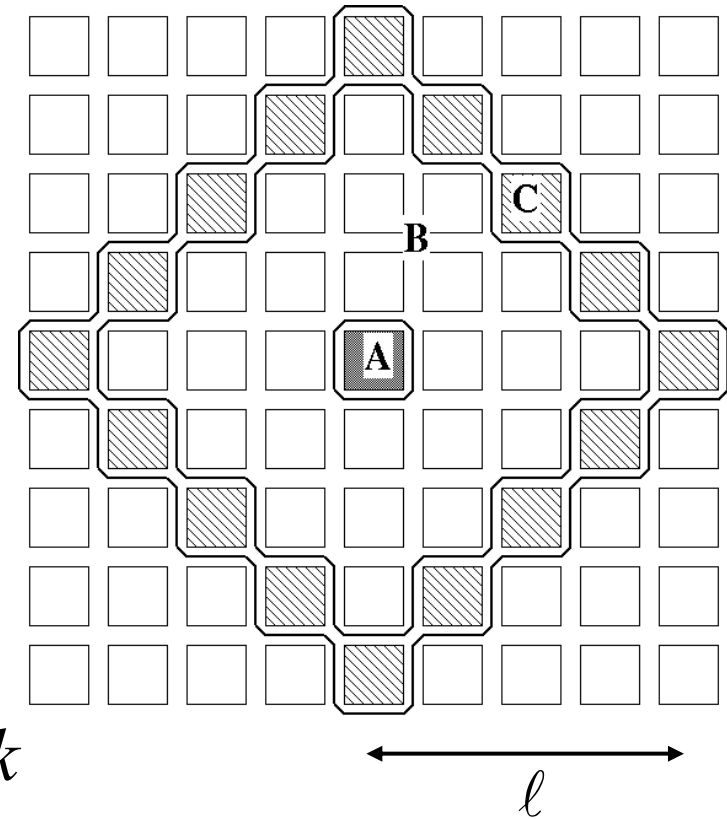
$$T_{A \leftrightarrow B}(\ell + 1) = T_{A \leftrightarrow B}(\ell) + T_{A \leftrightarrow C}(\ell)$$

and Rent's rule follows

$$\lim_{\ell \rightarrow \infty} T_{A \leftrightarrow B}(\ell) = \lim_{\ell \rightarrow \infty} \sum_{r=1}^{\ell-1} T_{A \leftrightarrow C}(r) = k$$

- A probability function can be defined by

$$\text{prob}_{A \leftrightarrow C}(\ell) = \frac{1}{k} T_{A \leftrightarrow C}(\ell)$$



- We want the occupation probability $q(\ell)$ to satisfy

$$k = \alpha k \sum_{\ell=1}^{\infty} 4\ell q(\ell) \approx \alpha k \int_0^{\infty} \frac{4\ell}{c_p} q(\ell) d\ell = \alpha \int q(\ell) k \frac{dS}{c_p}$$

k : Average number of terminals per cell

c_p : Cell pitch, $S = 2\ell^2$: Area of Manhattan circle

α : Terminal - to - wire conversion factor

$$\Rightarrow q(\ell) = \frac{1}{2\ell} \text{prob}_{A \leftrightarrow C}(\ell)$$